

Device Research for the MUSE Initiative

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Objective

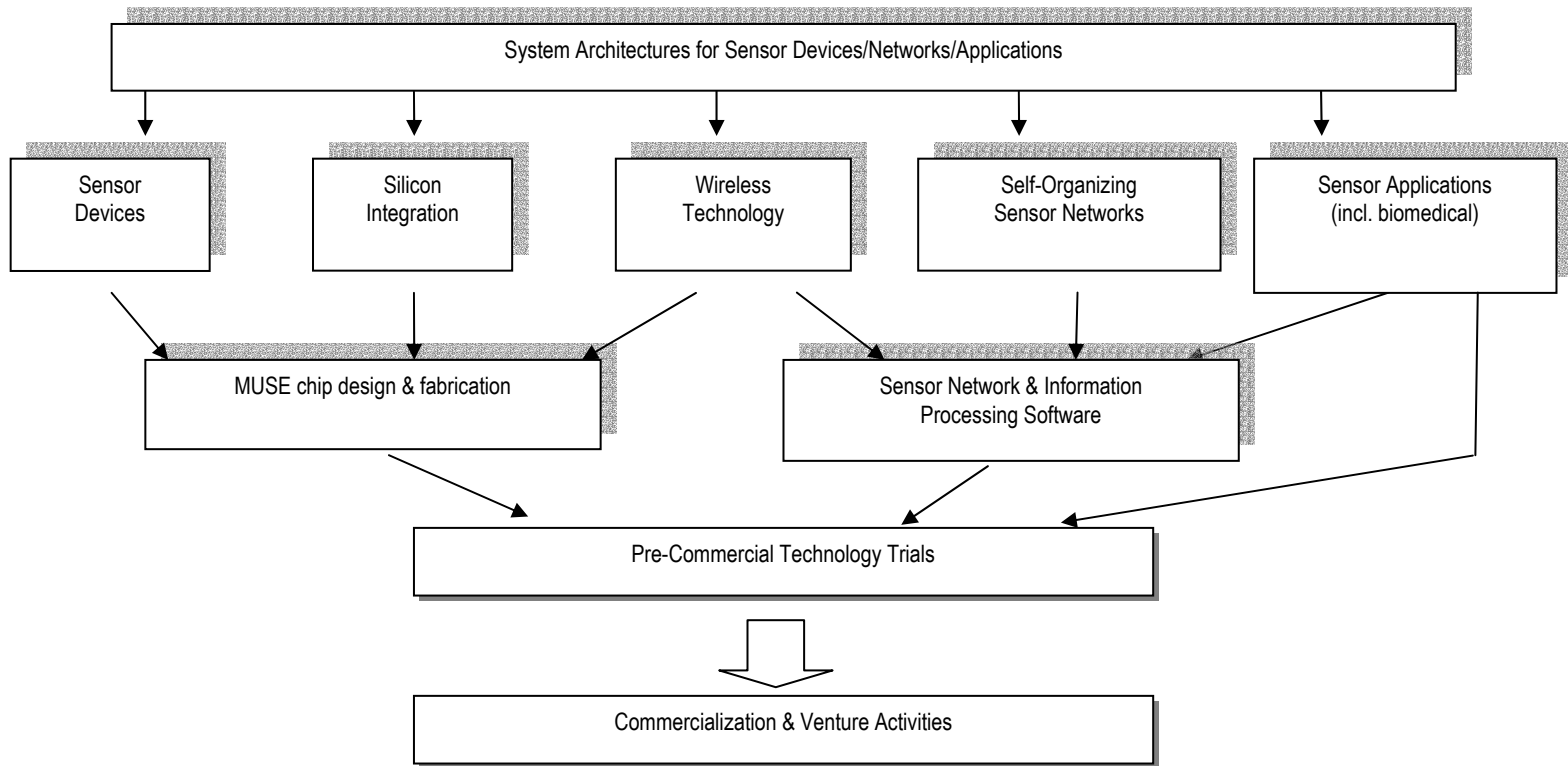
- Establish an interdisciplinary R&D Excellence Center for hosting collaborative research towards the development and transfer of multimodal integrated wireless sensor-on-silicon (MUSE) technology.

Focus on the following areas:

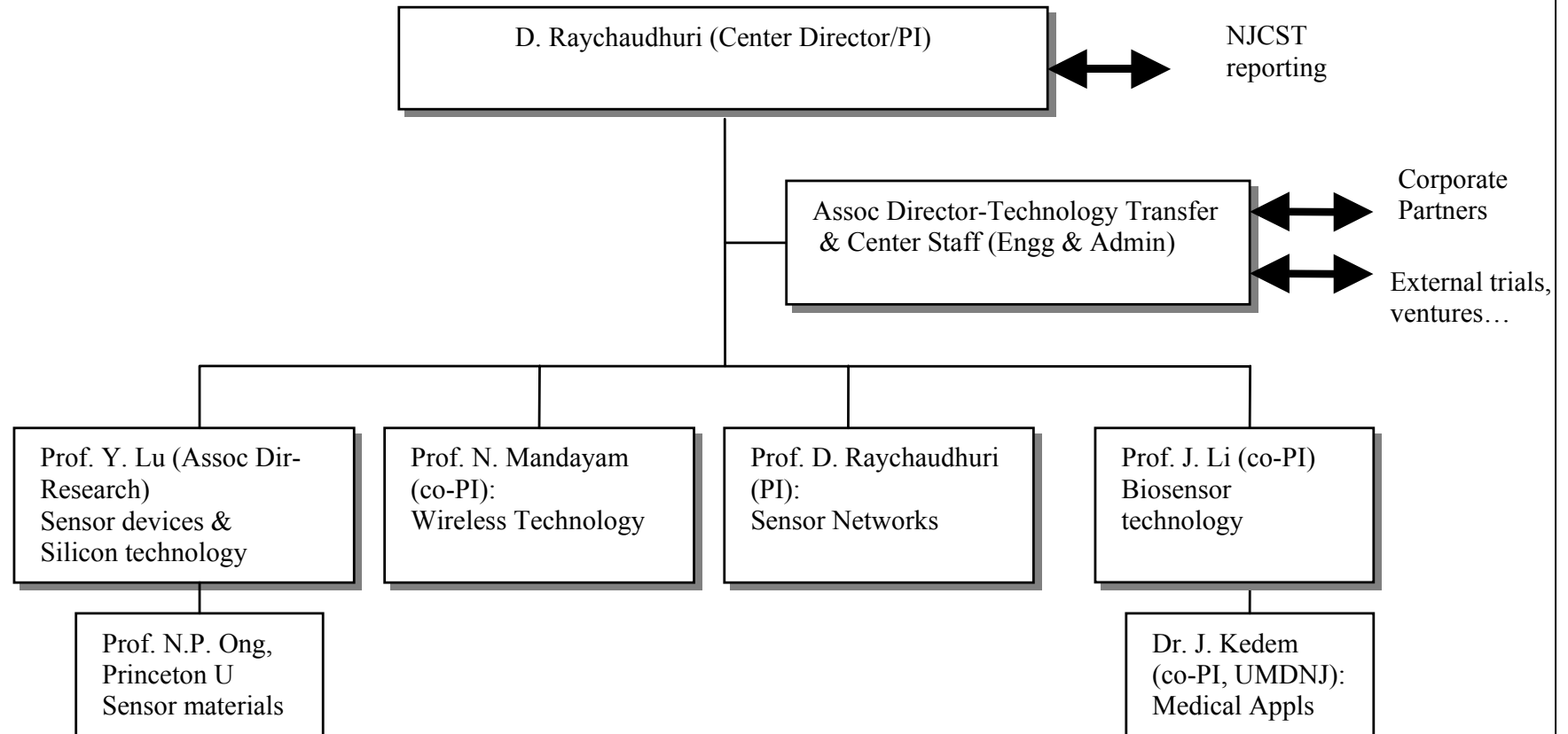
- Device technologies for multimode sensor modules (RF, optical, acoustic, mechanical & biochemical)
- Integrated sensor-on-silicon architecture for multi-modal wireless sensors
- Wireless communication module for low-cost, robust, self-organizing sensor networks
- Sensor network architecture, protocols and information processing software
- End-user applications and trials using prototype MUSE devices (with initial focus on biomedical uses)

Proposed Research Initiative

CENTER FOR MULTI-MODAL WIRELESS INTEGRATED SENSOR-ON-SILICON (MUSE) TECHNOLOGY

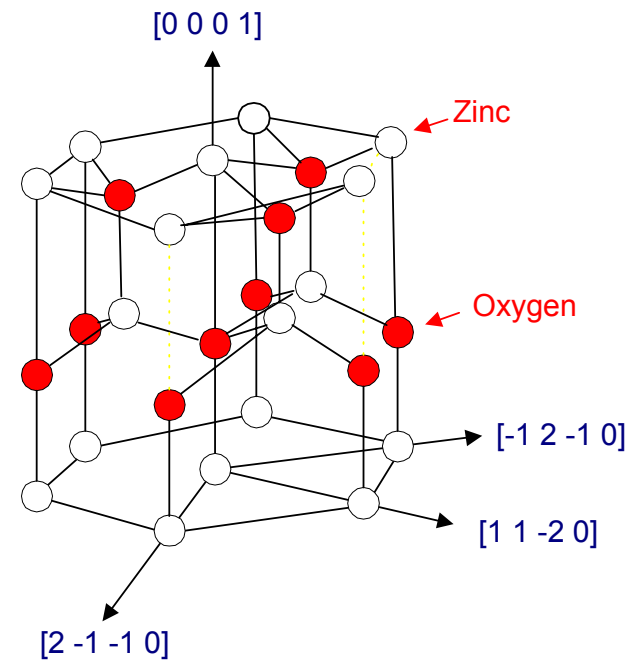


MUSE Research Team



Introduction: ZnO Materials

- II-VI compound semiconductor.
 - Direct bandgap, with $E_g \cong 3.32$ eV.
 - Bandgap engineering: alloy with Cd or Mg to tailor bandgap from 2.8eV to 4.0eV.
- Multi-functional:
 - Hexagonal wurtzite class crystal \Rightarrow piezoelectricity with large coupling coefficient.
 - Large and fast photoconductivity \Rightarrow optical sensing.
 - Al or Ga doping \Rightarrow transparent conductive oxide.
 - Li & Mg doping \Rightarrow ferroelectric.
 - Alloyed with Mn \Rightarrow magnetic oxide semiconductor.
- Integrate electrical, optical and piezoelectrical properties \Rightarrow MITSAW chip technology

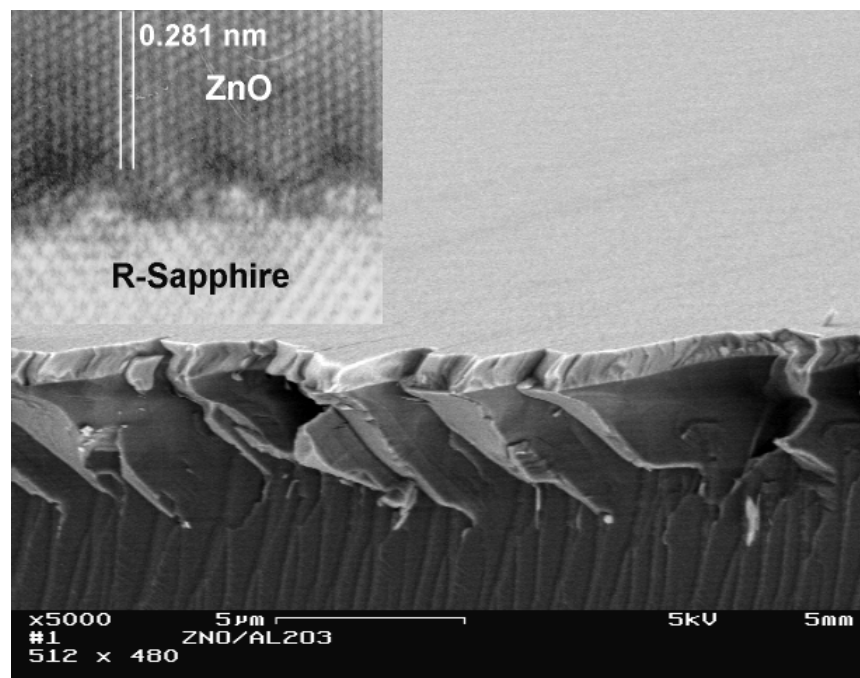


Achievements of ZnO Research at Rutgers

- High quality MOCVD ZnO and $\text{Mg}_x\text{Zn}_{1-x}\text{O}$ thin films on R- Al_2O_3 and SiO_2/Si .
- Low loss ZnO/R- Al_2O_3 SAW devices.
- The first high speed ZnO MSM photoconductive and Schottky UV photodetectors.
- The first optically addressed normal incidence ZnO UV high contrast modulator.
- The first ZnO Schottky devices on R- Al_2O_3 .
- Novel ZnO nanostructures.
- Novel MITSAW chip technology.

ZnO Growth on R- Al_2O_3

- Metalorganic chemical vapor deposition (MOCVD):
 - Precursors: Diethylzinc (DEZn), $(\text{MCP})_2\text{Mg}$, O_2
 - ECR microwave plasma
- Atomic scale sharp ZnO/ R- Al_2O_3 interface, semicoherent.
- Photoluminescence:
 - 6 meV @ 11K.
 - Bulk ZnO 3 meV @ 4.2K.

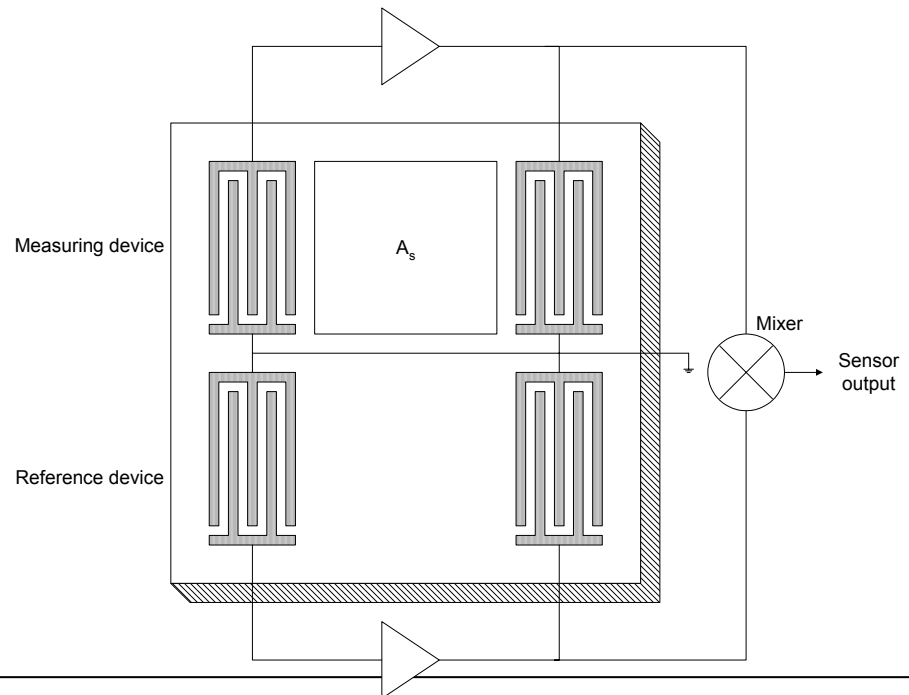


Challenges for Biosensors

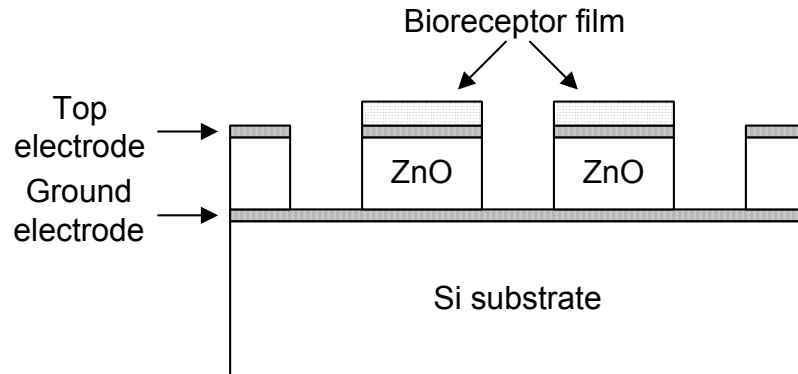
- Integration of sensors to obtain multiplexed functionality
- Development of sensor interface to relate its output to physiologically or clinically meaningful parameters
- Reduction or elimination of sensor biofouling
- Develop wireless networking technology for sensors
- Ensuring a cost-effective solution

SAW Sensors: Dual Channel Oscillator

- Selective coating placed between the two IDTs of the measuring SAW device.
- Mass loading effect will change the center frequency of the oscillator circuit.
- Reference device to eliminate deviations due to external effects.
- Sensor output = frequency difference between the two oscillator circuits.
- Can be arrayed to obtain multi-channel arrays.



Micromachined BAW(TFR) Sensor Arrays



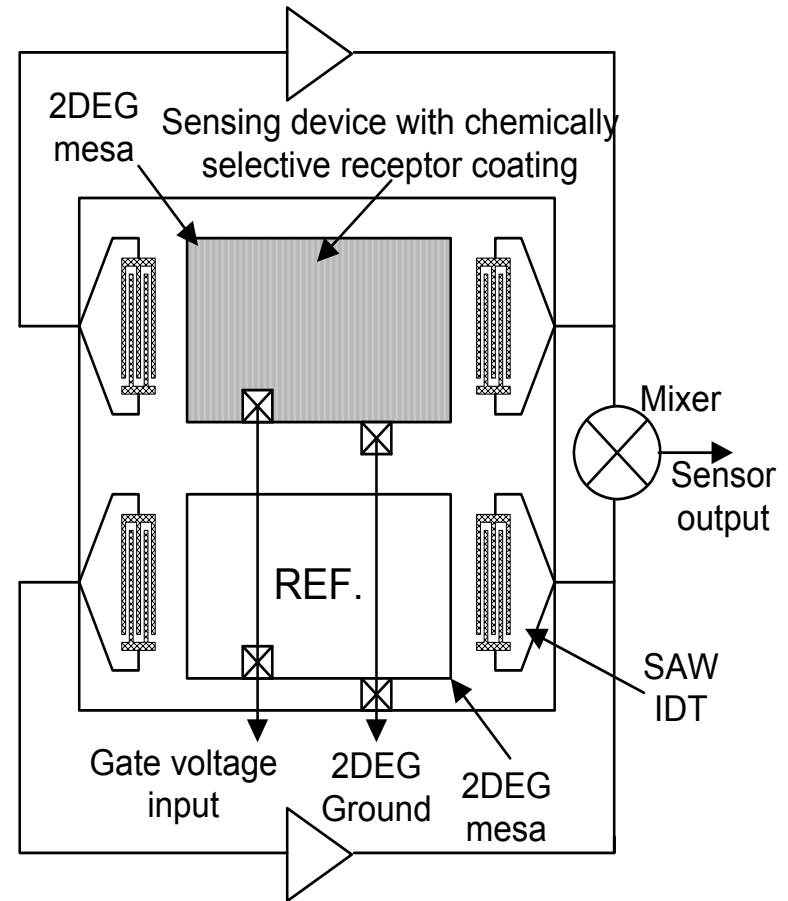
- An array of micromachined thin film resonators (TFRs) will selective coatings.
- A large number of target materials can be detected and measured on the surface area of the same chip.
- Can be integrated with electronic circuits => smart sensor.
- Dramatically improve sensor reliability and allow detection and measurement of multiple chemicals simultaneously.

MITSAW Operation and Advantages

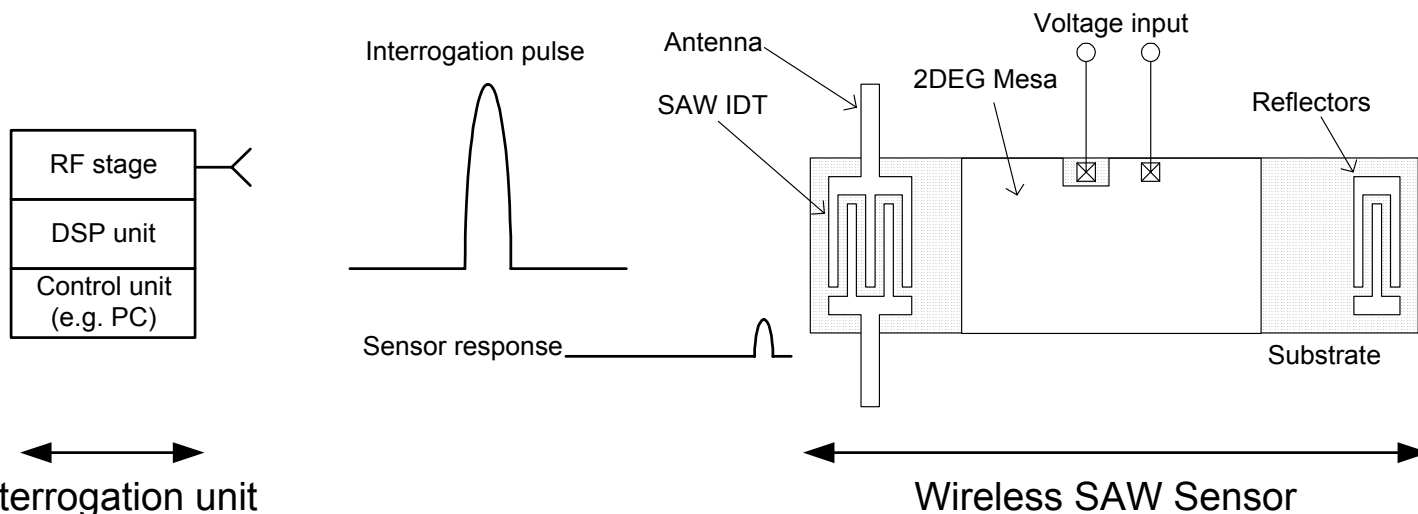
- Operation:
 - Integration of 2DEG and SAW in the ZnO/R-Al₂O₃ material system.
 - Interaction of the electronic field of SAW with 2DEG results in slowing of the SAW velocity.
 - 2DEG density is controlled by reverse bias voltage across the Schottky barrier, thus the acoustic velocity can be controlled by the bias voltage.
- Advantages:
 - Excellent manufacturability, high yield and low cost.
 - High electromechanical coupling coefficients and high SAW velocity \Rightarrow high frequency and low loss RF devices.
 - The in-plane anisotropy of electrical, optical and acoustic properties.
 - Multi-functionality and broad applications.

MITSAW Application to Biosensors

- MITSAW sensor can be “reset” by tuning SAW velocity, therefore, increases the sensor lifetime.
- Multiple wave modes for increased sensitivity in gas or liquid sensing environment.
- Dual mode (acoustic and UV optic) operation: to improve identification and sensitivity.



Zero-Power Remote Wireless Sensors



- Base station sends interrogation pulse.
- The antenna picks the pulse; the SAW IDT launches a wave packet.
- The wave packet travels across the delay path, is reflected by the reflecting array.
- The reflected wave generates a signal at the IDT.
- The antenna send a response pulse.
- 2DEG bias determines acoustic velocity, hence response delay time.
- Thus the device is a wireless read-out element for a voltage-generating sensor.

Mg_xZn_{1-x}O UV Detectors

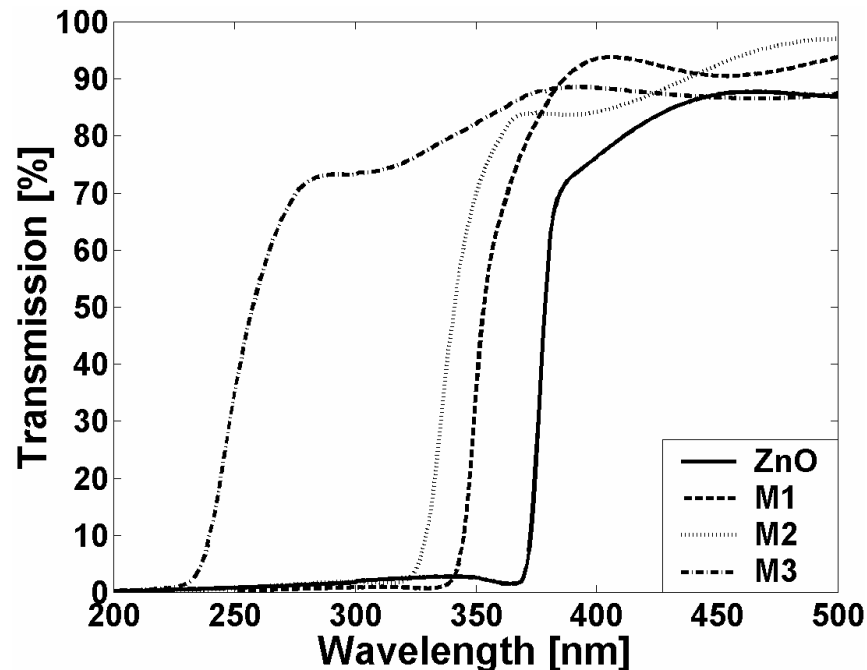
- Applications:
 - Biosensors (biochemicals have unique UV spectra)
 - Environmental monitoring and protection (chemical, fire, smoke, etc.)
 - Aerospace engineering (solar-blind, UV sensitive)

ZnO 373 nm

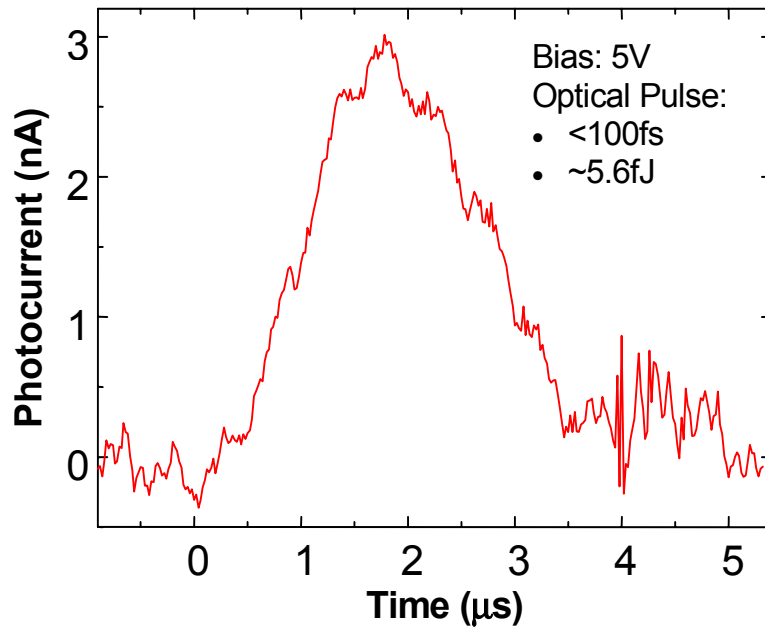
M1 345 nm

M2 329 nm

M3 240 nm

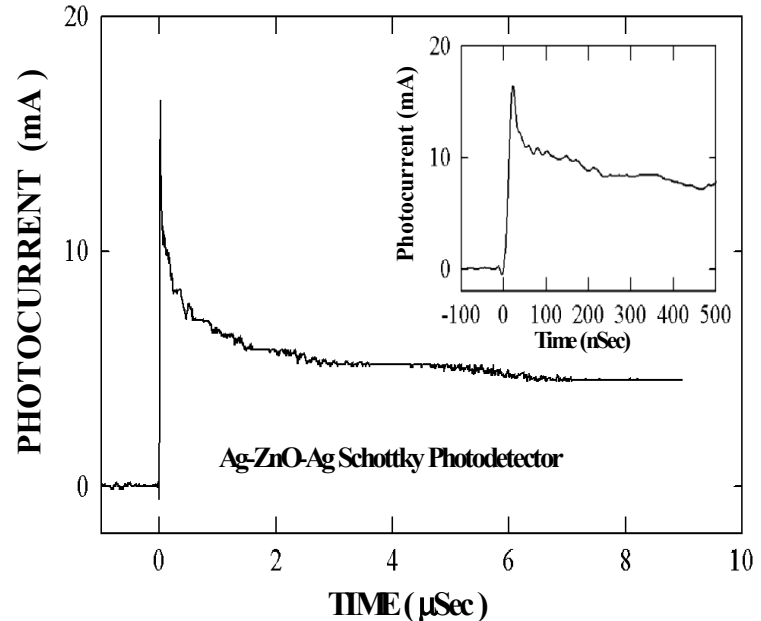


Photocurrent vs. Response Time of a Photoconductive and Schottky Photodetector



A. Photocurrent vs. Response Time of a Photoconductive Photodetector

Rise Time: 1 μ s
Fall Time: 1.5 μ s



B. Photocurrent vs. Response Time of a Schottky Photodetector

Rise Time: 12ns
Fall Time: 50ns

Integrating ZnO with Si: Advantages

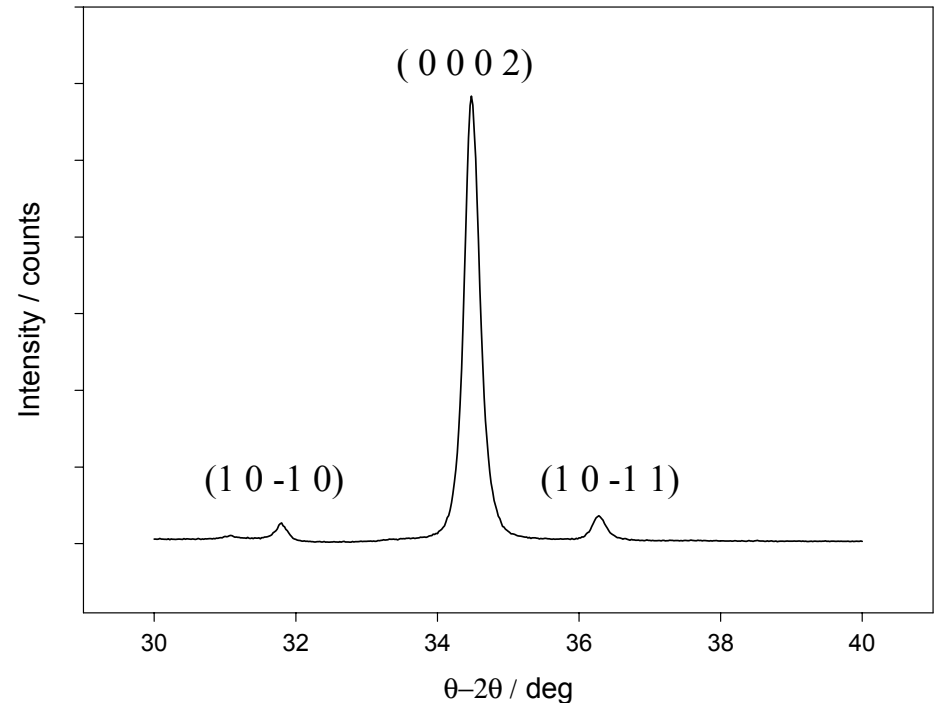
- SAW devices can be integrated with Si ICs.
 - Almost all ICs use a Si substrate.
 - Thermally grown SiO_2 is available in most IC processes.
- The SiO_2 acts as a temperature compensation layer to improve the temperature stability.
 - ZnO and Si have positive temperature coefficient of delay (TCD).
 - SiO_2 has negative TCD.
- Temperature compensated frequency responses can be obtained by optimizing the ZnO to SiO_2 thickness ratio.
- MOCVD growth of ZnO is done at low temperatures, therefore junction movement is minimized.

Integration with Si: Two-Step ZnO Growth

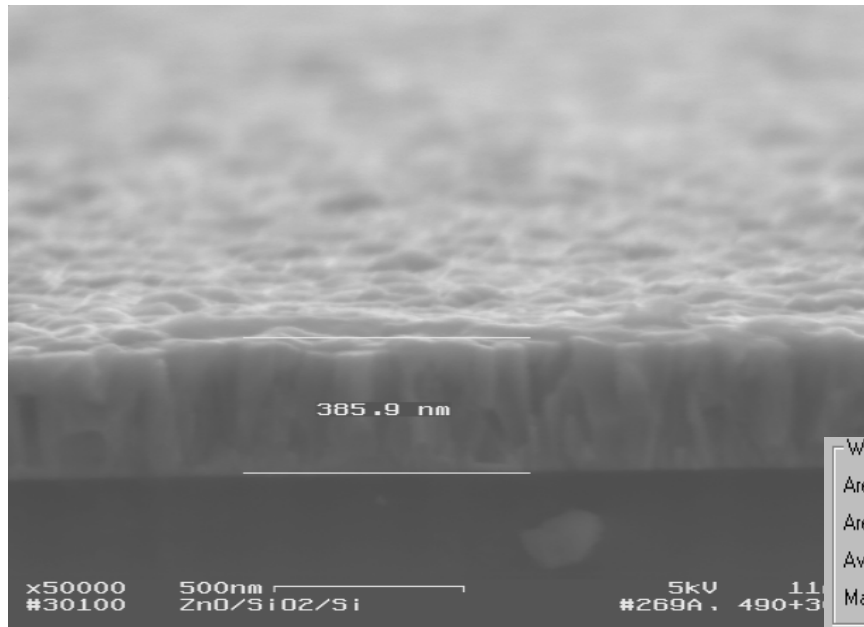
- **High growth temperature:** predominantly c-axis oriented, rough surface morphology.
- **Lower growth temperatures:** smooth surface morphology, poor crystallinity.

Two-Step Growth:

- Relatively high T buffer layer => stable crystalline template for subsequent low T step.
- Crystallinity maintained: ZnO film that nucleates on the buffer layer continues the atomic arrangement of the previous layer.

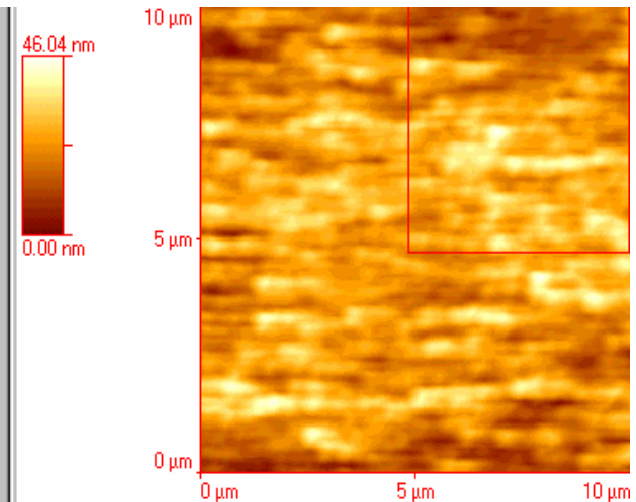
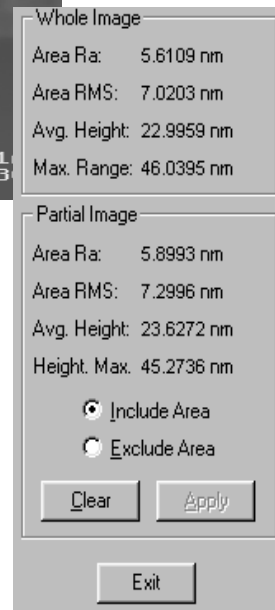


Two-Step Growth of ZnO/SiO₂/Si



- The ZnO buffer layer is initially grown at 490°C for 1-5 mins. followed by a top layer grown at 300°C-340°C.

- The films are highly c-axis oriented.
- The surface morphology is very smooth with an average RMS roughness of 7nm.



Patents and Invention Disclosures

Related Patents

- “High Contrast, Ultrafast Optically Addressed Ultraviolet Light Modulator Based Upon Optical Anisotropy in ZnO Films Grown on R-plane Sapphire” (with M. Wraback, H. Shen, S. Liang and C.R. Gorla), Aug. 17, 1999, Provisional Patent Application ARL 99-66
- “Monolithically Integrated Tunable Surface Acoustic Wave Technology and Electrical Systems Provided Thereby” (with N.W. Emanetoglu), filed July 13, 2001
- “Surface Acoustic Wave Technology and Sensors Provided Thereby”, (with N.W. Emanetoglu), filed July 13, 2001

Recent Invention Disclosures

- “Fabrication of Ag Schottky contacts on () $Mg_xZn_{1-x}O$ ” (with H. Sheng, S. Muthukumar, N.W. Emanetoglu, J. Zhong), filed Dec. 2001
- “Tailoring Piezoelectric Properties Using $Mg_xZn_{1-x}O$ and $Mg_xZn_{1-x}O/ZnO$ Structures” (with N.W. Emanetoglu), filed Dec. 2001
- “Selective Growth and Fabrication of ZnO Single Nanotip and ZnO Nanotip arrays” (with S. Muthukumar), filed Feb. 2002

Conclusions

1. ZnO is a promising sensing material:

- Multifunctionality
- Tunability/ Resetability (reducing biofouling)
- Integratable with Si and Si-on-Sapphire substrates
- Manufacturability (low cost)

2. ZnO based sensor devices have broad applications:

- UV sensors (biochemical, aerospace, etc.)
- Biosensors (SAW, BAW, nanotip)
- Wireless passive sensors (zero power consumption)
- Magnetic sensors (spintronics)
- High energy particle sensors (radiation-hardness)
- MITSAW sensors (multifunctional, resetable, tunable)

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